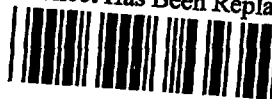


ABSTRACT OF THE DISCLOSURE

A polishing solution supply system can prevent precipitation of solutes on delivery pipes or interior walls of holding tanks so that a polishing solution of a constant solution concentration can be supplied to a polishing tool. The polishing solution supply system comprises a stock solution supply source, a dilution solution supply source, and a mixing section for mixing a stock solution and a dilution solution to formulate the polishing solution. The mixing section is sealed hermetically to exclude external atmosphere. A delivery line to deliver the polishing solution to each of the polishing section is provided.

This Sheet Has Been Replaced



THIS SHEET HAS BEEN
REPLACED